SP 2 5 2003 W

our Docket No: 42P10058

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applica	tion of:)		
Han-Ming Wuet al.)	Examiner:	Nguyen, Hung
Serial No:	09/752,938)	Art Unit:	2851
Filed:	December 29, 2000)		
For:	Purging Gas from a Photolithography Enclosure Between a Mask Protective Device and a Pattern Mask))) _)		
PRELIMINARY AMENDMENT				
Sir:	er for Patents		olication, pleas	se enter the following
FIRST CLASS CERTIFICATE OF MAILING				
Service as first cla	at I am causing the above-referenced cornss mail with sufficient postage on the date commissioner for Patents, P.O. Box 1450	e indicat	ed below and that th	is paper or fee has been
September 23, 2003				
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Must	Name of Person Ma	Mathiesor	respondence September 23, 200	3
Signature			Date	